## IN THE CLAIMS

Please amend the claims as follows:

Claims 1-5 (Cancelled).

Claim 6 (Currently amended): An ultrasonic sensor comprising:

a semiconductor crystal substrate having a recess formed on a part of an upper surface thereof;

a  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> single crystal film epitaxially grown on a semiconductor single crystal substrate;

an epitaxial single crystal Pt thin film disposed on the γ-Al<sub>2</sub>O<sub>3</sub> single crystal film;

a highly oriented ferroelectric thin film disposed on the epitaxial single crystal Pt thin film; and

an upper electrode disposed on the ferroelectric thin film;

wherein

the γ-Al<sub>2</sub>O<sub>3</sub> single crystal film overhangs the recess formed on a part of the upper surface of the semiconductor crystal substrate;

the semiconductor single crystal substrate is subjected to a treatment for adjusting etched from the upper surface thereof to adjust a resonant frequency and detect an ultrasonic wave to be detected.

Claim 7 (Previously presented): The ultrasonic sensor according to Claim 6, wherein the semiconductor single crystal substrate has an SOI structure.

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Claims 8-11 (Cancelled).

Claim 12 (Previously presented): The ultrasonic sensor according to Claim 6, wherein the semiconductor single crystal substrate is a Si single crystal.

Claim 13 (Previously presented): The ultrasonic sensor according to Claim 12, wherein the  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> single crystal film epitaxially grown on a semiconductor single crystal substrate is grown on a (100) face of the Si single crystal.

Claim 14 (Previously presented): The ultrasonic sensor according to Claim 6 wherein the highly oriented ferroelectric thin film disposed on the epitaxial single crystal Pt thin film comprises one selected from the group consisting of BaMgF<sub>4</sub>, Bi<sub>4</sub>Ti<sub>3</sub>O<sub>12</sub>, (Bi,La)<sub>4</sub>Ti<sub>3</sub>O<sub>12</sub>, BaTiO<sub>3</sub>, Ba<sub>x</sub>Sr<sub>1-x</sub>TiO<sub>3</sub>, SrBi<sub>2</sub>Ta<sub>2</sub>O<sub>9</sub>, PbTiO<sub>3</sub>, Pb<sub>y</sub>La<sub>1-y</sub>Zr<sub>x</sub>Ti<sub>1-x</sub>O<sub>3</sub>, and ZnO.

Claim 15 (Previously presented): The ultrasonic sensor according to Claim 6 wherein the upper electrode disposed on the ferroelectric thin film comprises gold black.